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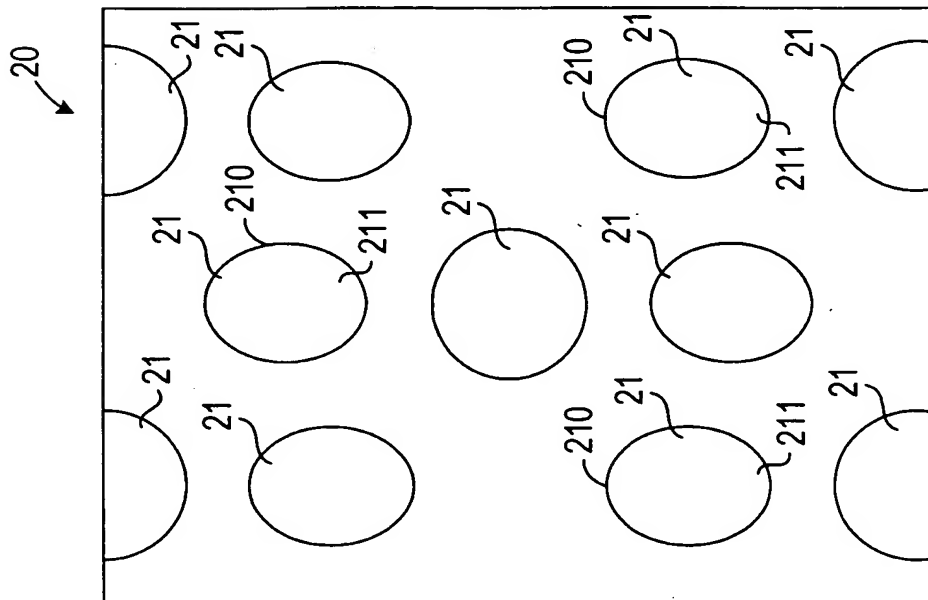


FIG. 2

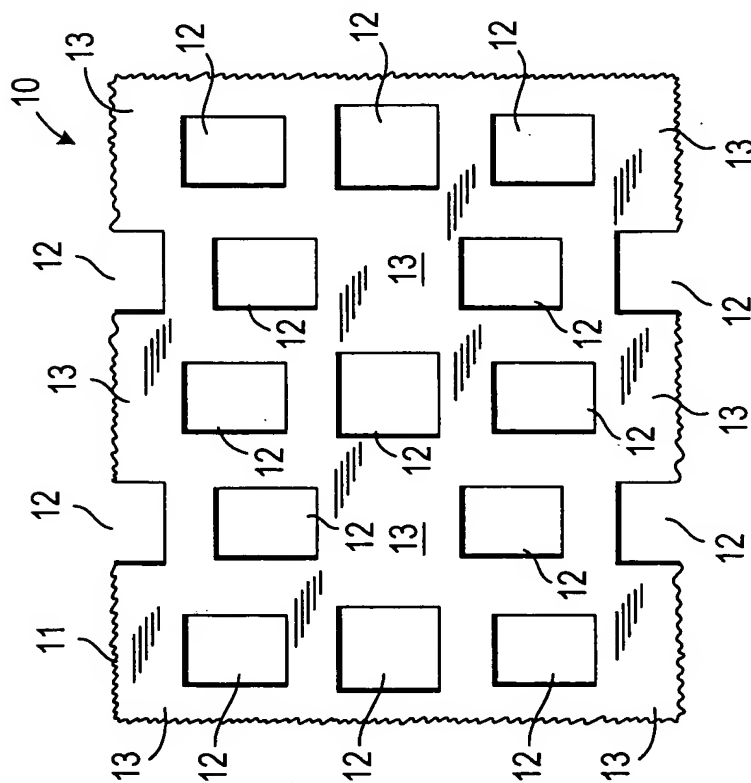


FIG. 1

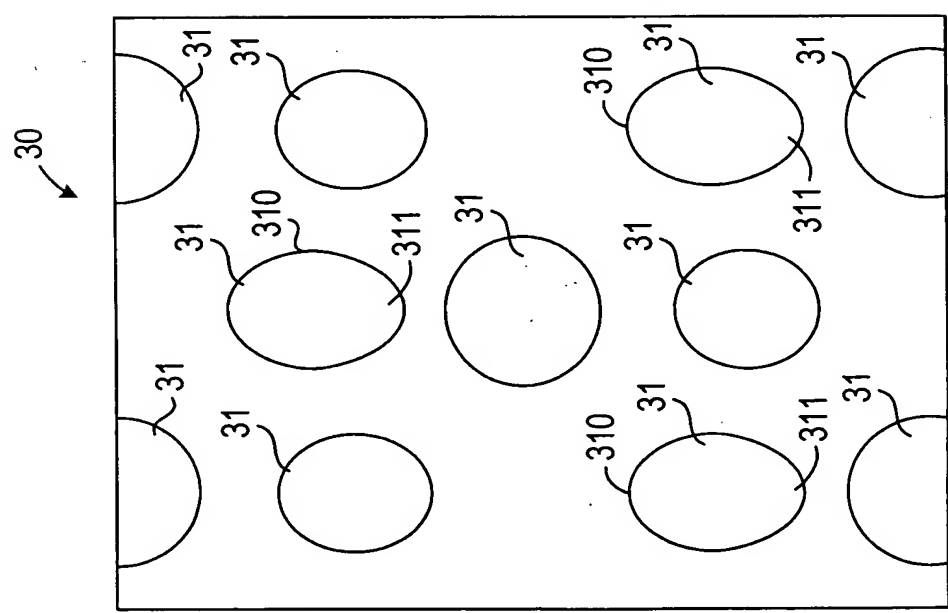


FIG. 3

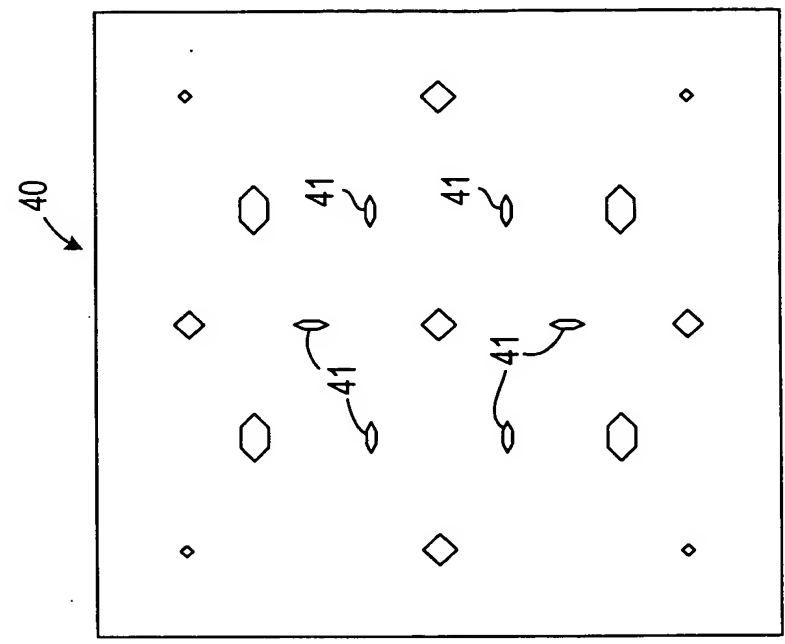


FIG. 4



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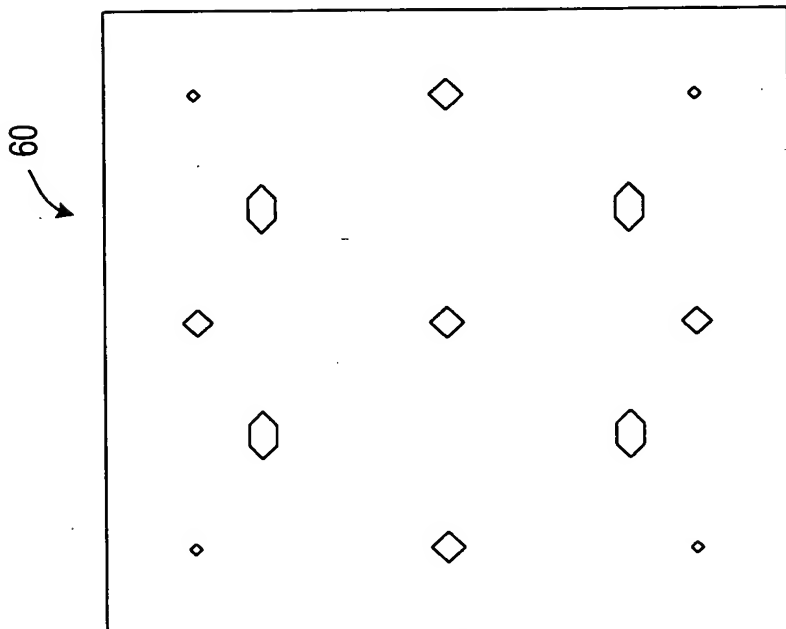


FIG. 6

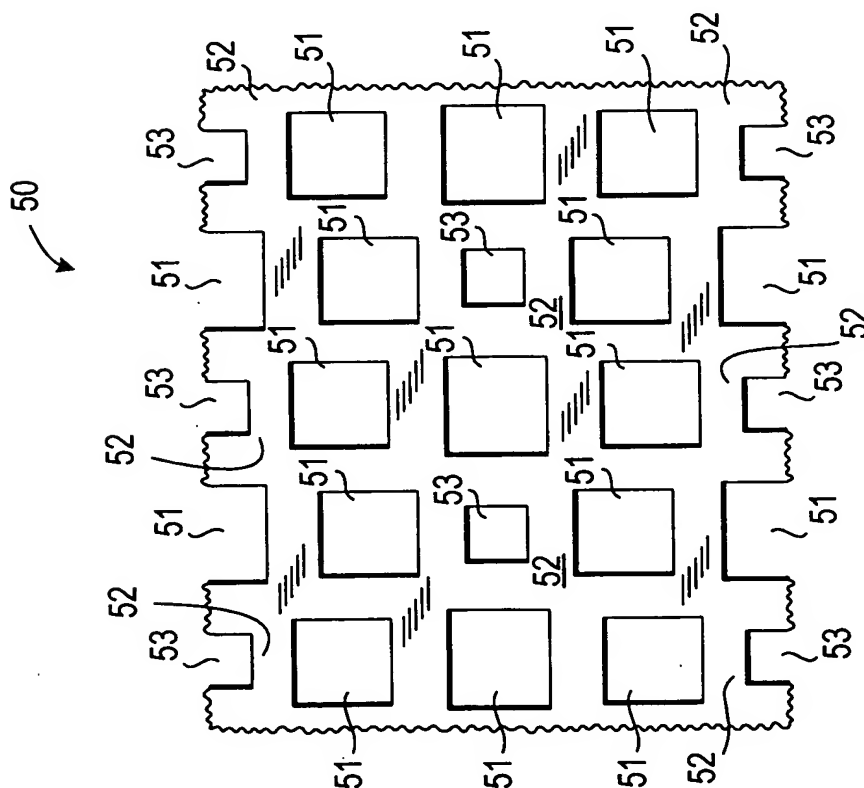


FIG. 5



Applicants: Pary Baluswamy et al. Docket No.: MIC-20 Filed: March 1, 2002
Application No.: 10/090,073 Confirmation No.: 4253
For: PATTERN MASK WITH FEATURES TO MINIMIZE THE EFFECT OF ABERRATIONS
Attorney: Jeffrey H. Ingerman, Reg. No. 31,069 Corrected Sheet 4 of 5

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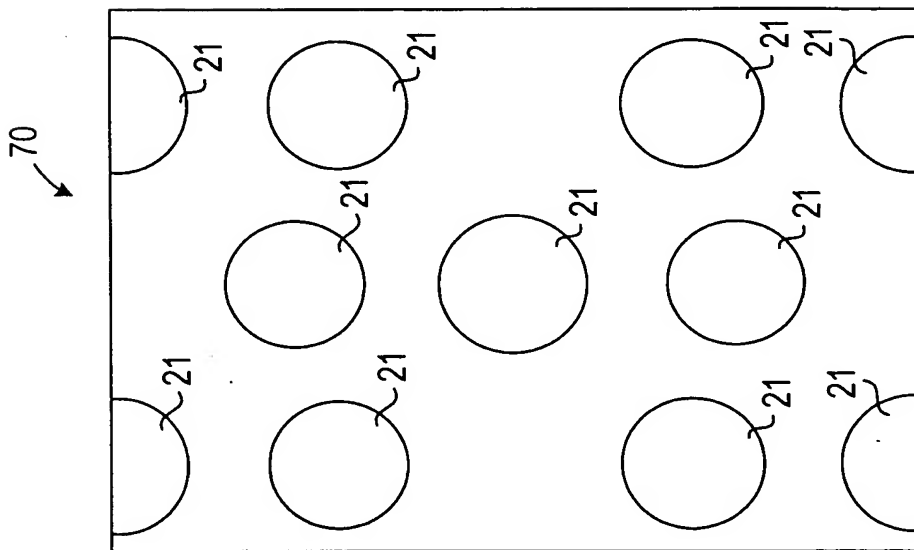


FIG. 7



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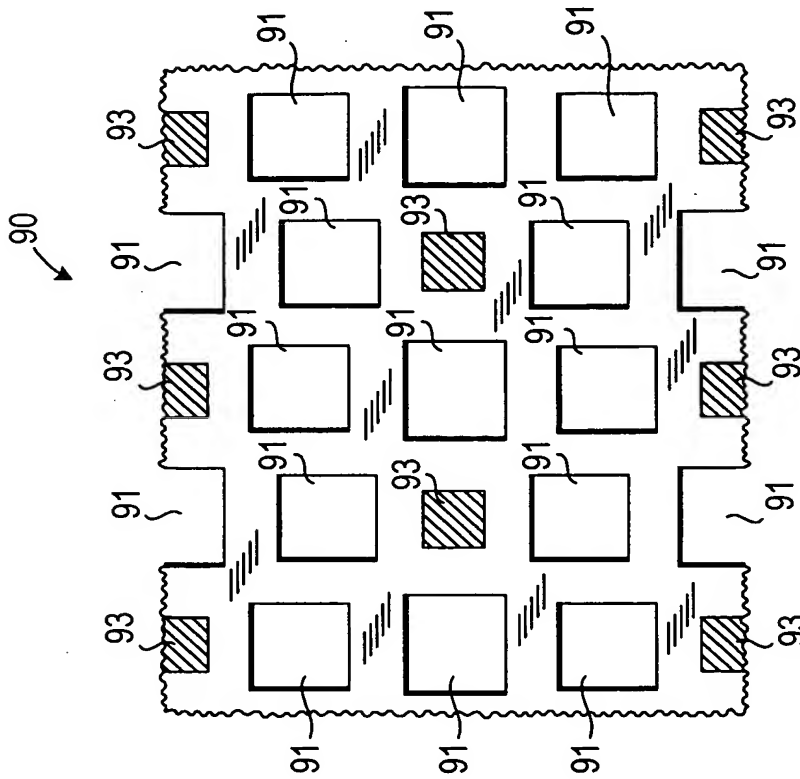


FIG. 9

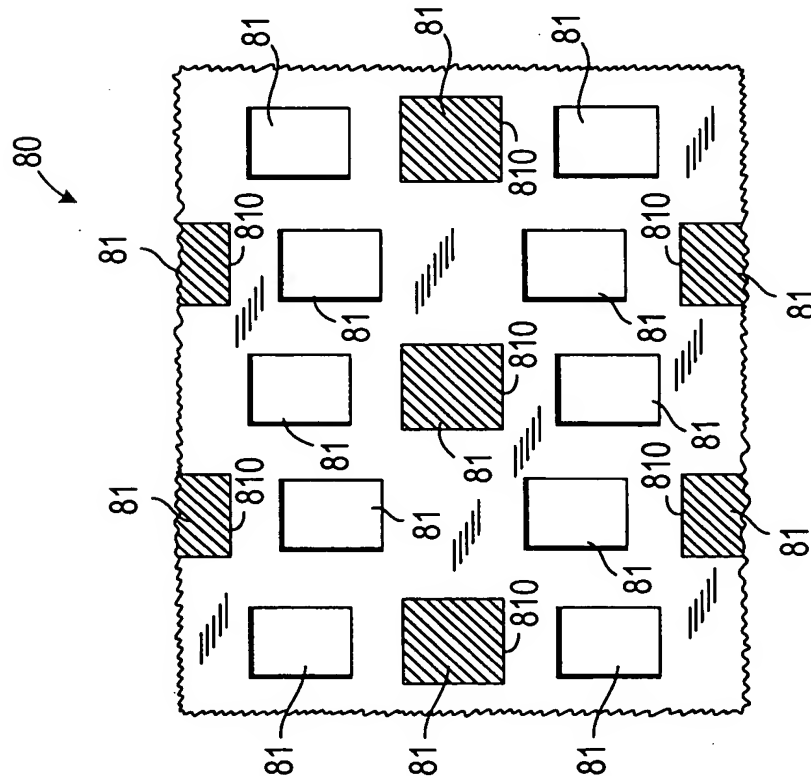


FIG. 8